

Measurement of Plasma Density of Fluorescent Lamp using 94-GHz Interferometer System*

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Pohang University of Science and Technology

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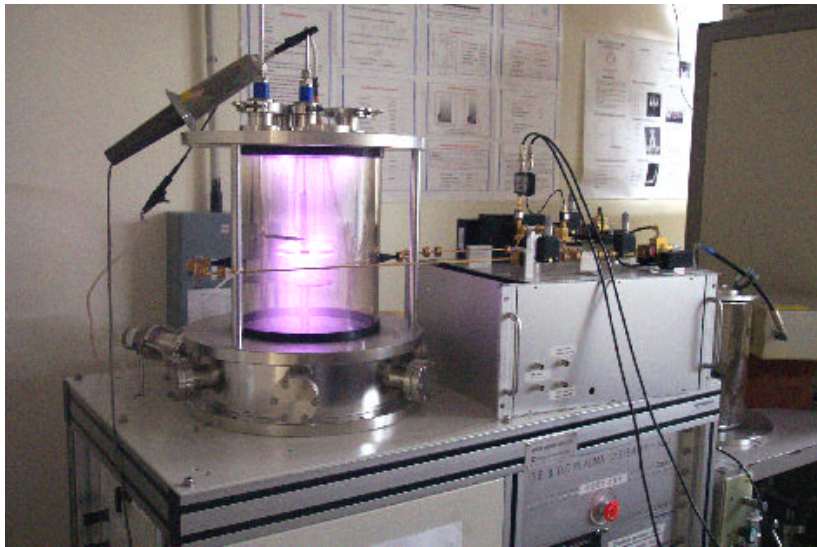
* Supported by KSTAR Project at KBSI.

Abstract

- The microwave interferometer system is a well-established technique for measurements of line-integrated plasma densities without perturbing plasma. The plasma density of a fluorescent lamp is measured by a 94-GHz interferometer system. We used 94- and 94.2-GHz Gunn oscillators, and a balanced mixer with down conversion. We observed a density modulation of 60 Hz in the output voltage of the phase comparator. The results are compared with the data measured with the network analyzer considering collisional effect. The line-integrated plasma density of the fluorescent lamp was about $5 \times 10^{11}/\text{cm}^{-3}$.

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Schematics of Microwave Interferometers

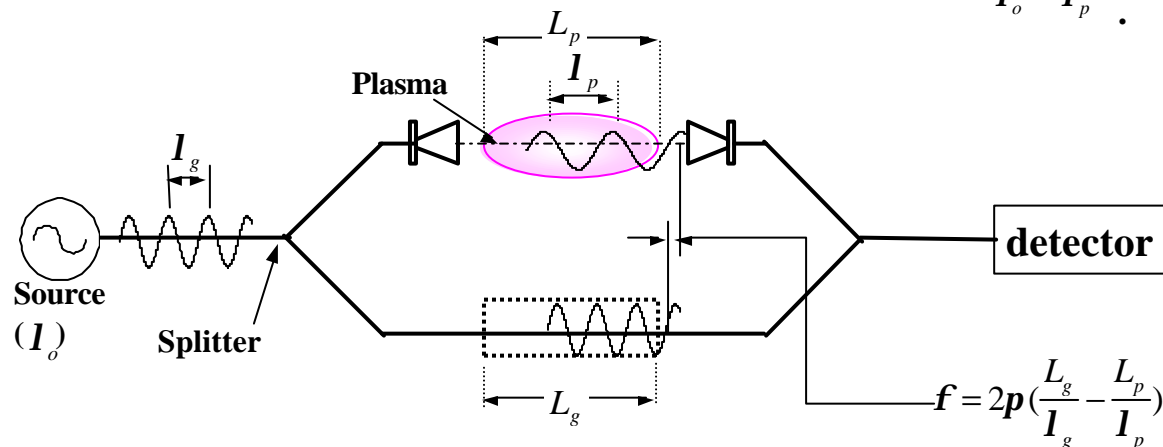


The wavelength in the plasma is always longer than in vacuum

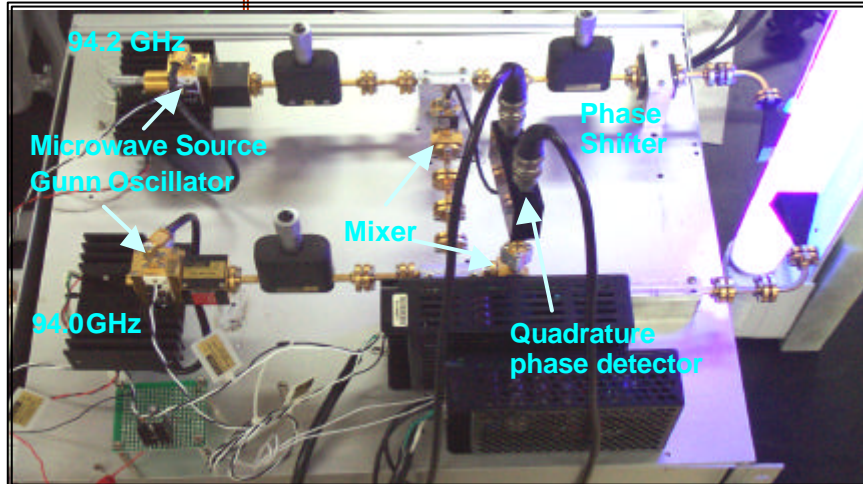
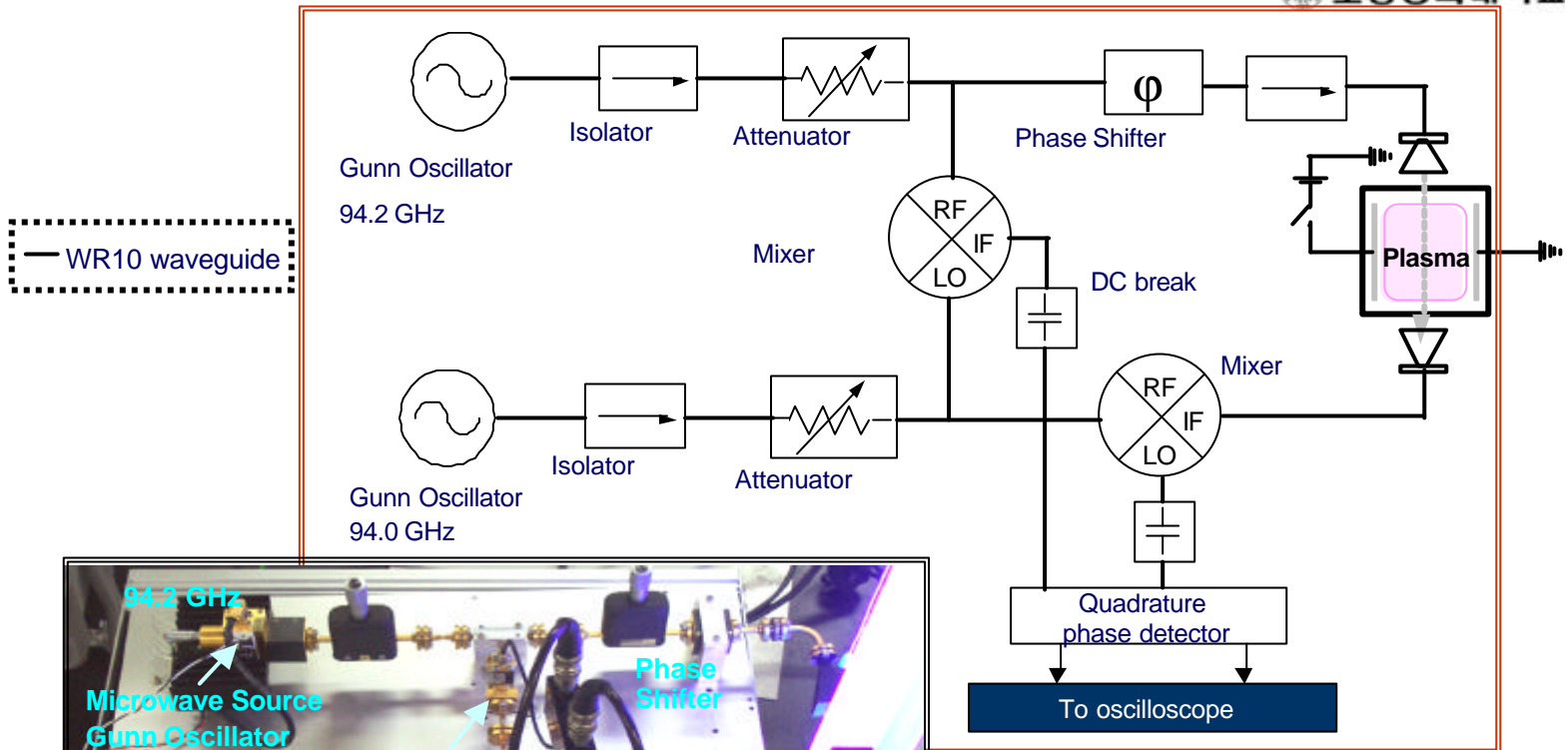
$$I_p = I_o \left(1 - \frac{w_p^2}{w^2}\right)^{-1/2} .$$

The phase difference between when there is a plasma and when not is then

$$\Delta f = 2p L_p \left(\frac{1}{I_o} - \frac{1}{I_p}\right) .$$

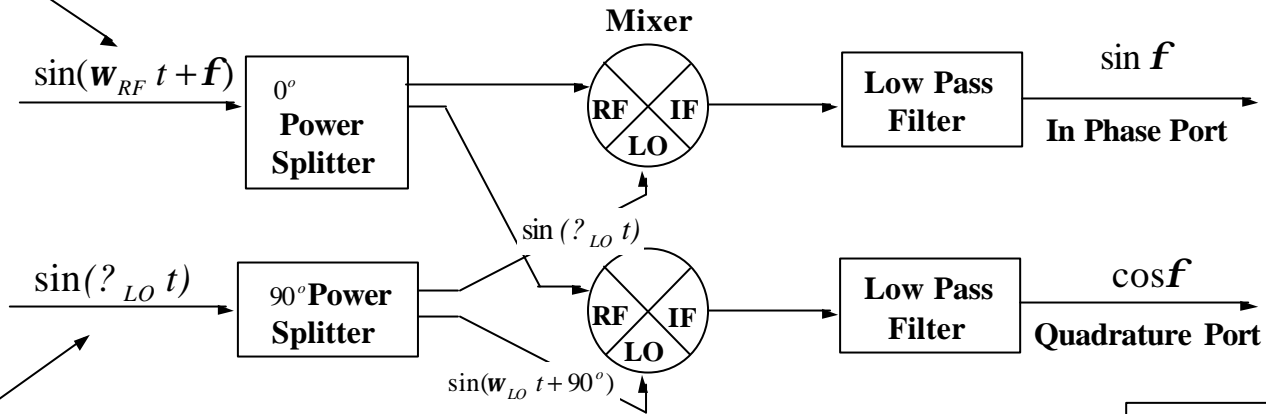


Microwave Interferometers (Heterodyne type)

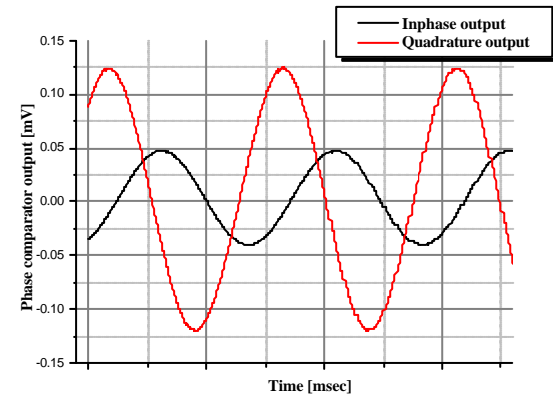


Quadrature Phase Detector (Phase Comparator)

Passed plasma



Reference signal



Plasma density calculation

- Because of the non-linearity of the phase quadrature phase detector, the digitized value (I and Q) should be corrected before the phase shift calculation.

$$I = K_I \sin[2\pi (f_{RF} - f_{LO})t] + V_{OI}$$

$$Q = K_Q \cos[2\pi (f_{RF} - f_{LO})t + \phi_o] + V_{OQ}$$

where, $2\pi(f_{RF} - f_{LO})$ is $\phi(t)$,

K_I, K_Q are output amplitudes ,

V_{OI} and V_{OQ} are dc - offset,

and ϕ_o is phase balance.

$$\phi(t) = \tan^{-1} \left(\frac{\cos(\phi_o)}{M + \sin(\phi_o)} \right) \quad \text{where, } M = \frac{Q - V_{OQ}}{I - V_{OI}} \frac{K_I}{K_Q}$$

- Phase shift due to plasma

$$f(t) = \frac{1}{c} \int_{-a}^{+a} \left[1 - \frac{v^2}{c^2} \right]^{1/2} dr$$

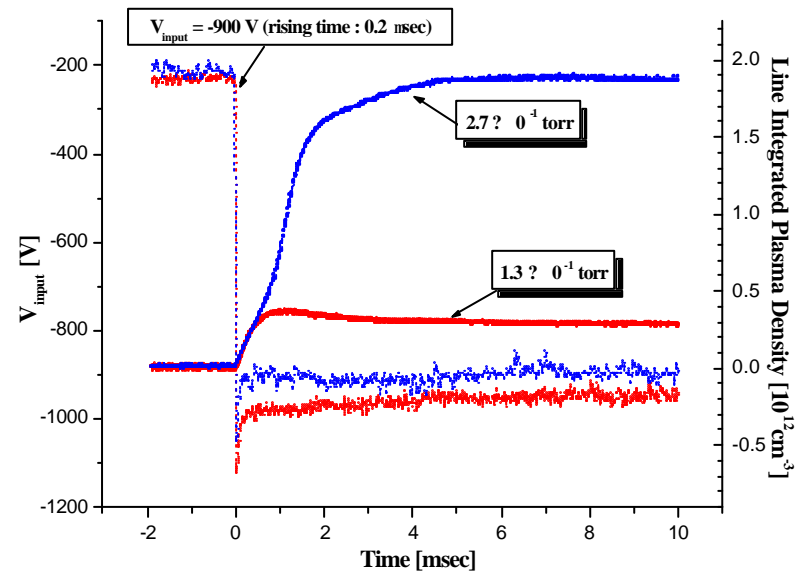
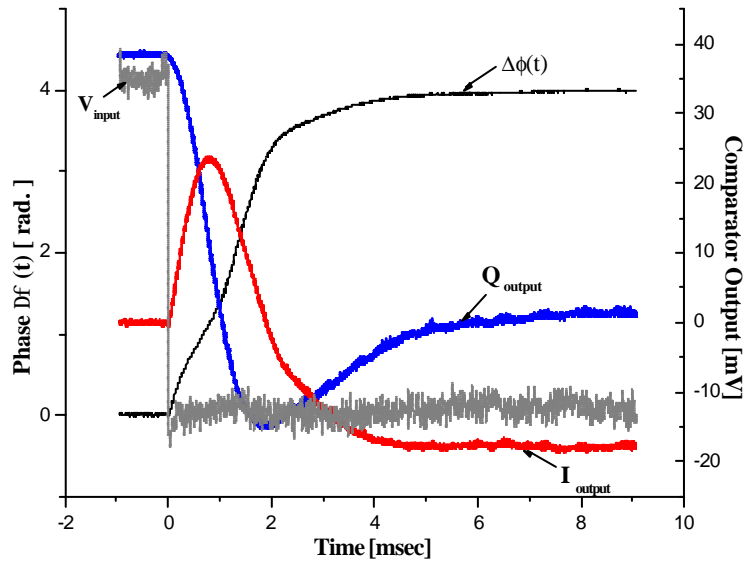
$$\cong 8.42 \times 10^{-16} \frac{1}{f_o(\text{GHz})} \int n_e(r, t) dr (m^{-3}), \text{ for } v \ll c \quad \text{where, } f_o \text{ is } 94.2 \text{ GHz}$$

- Therefore, the line-averaged electron density is

$$\langle n(m^{-3}) \rangle = \frac{1}{L} \times 1.18 \times 10^{15} f(\text{GHz}) \times \phi(t)$$

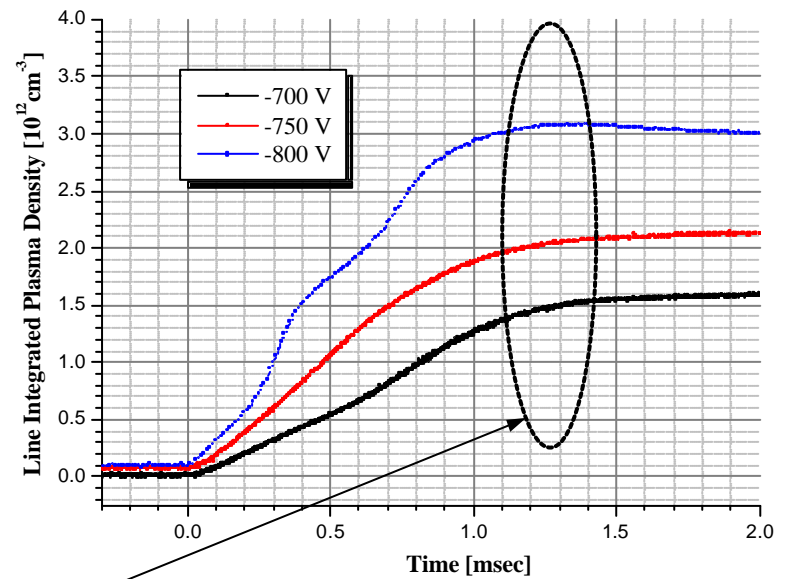
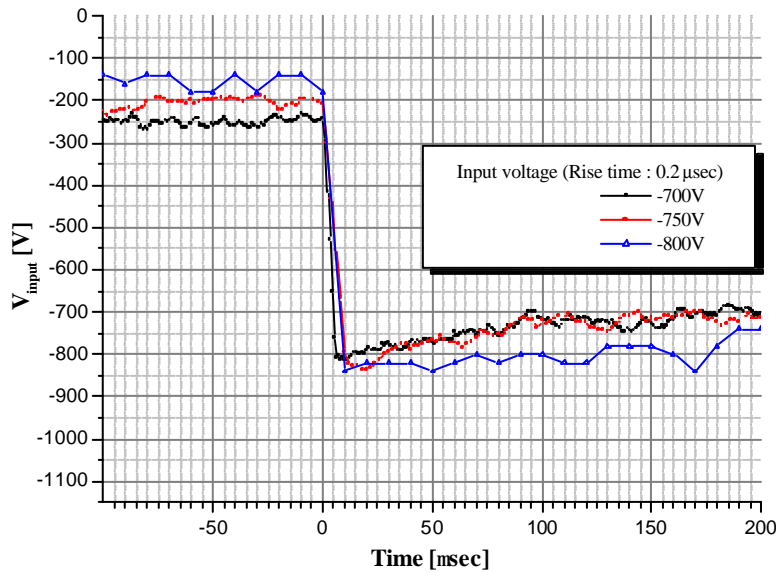
Variation of Plasma density over the DC input

Case I : Variation of pressure



Variation of Plasma density over the DC input

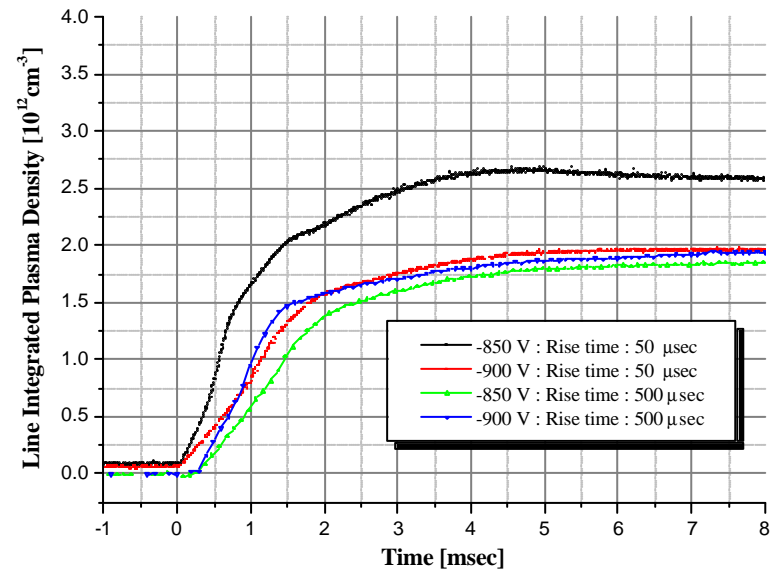
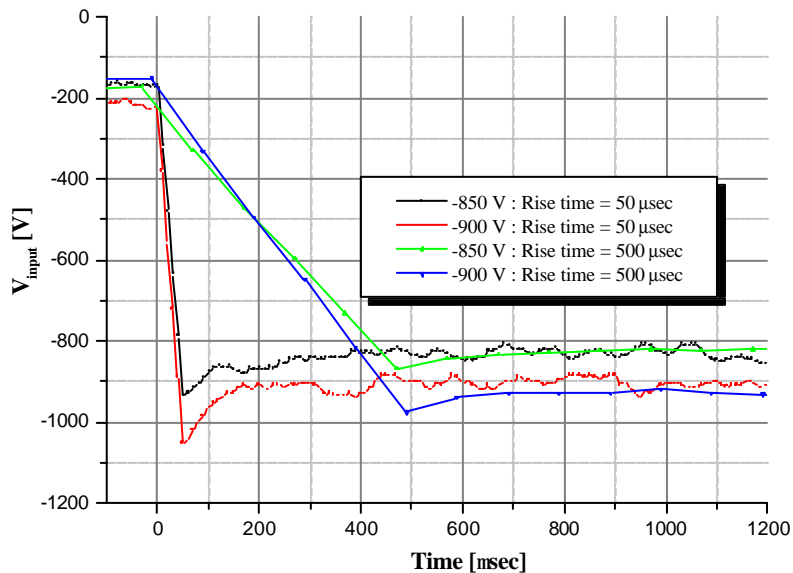
Case II : Variation of voltage



The plasma density reaches a maximum almost the same time.

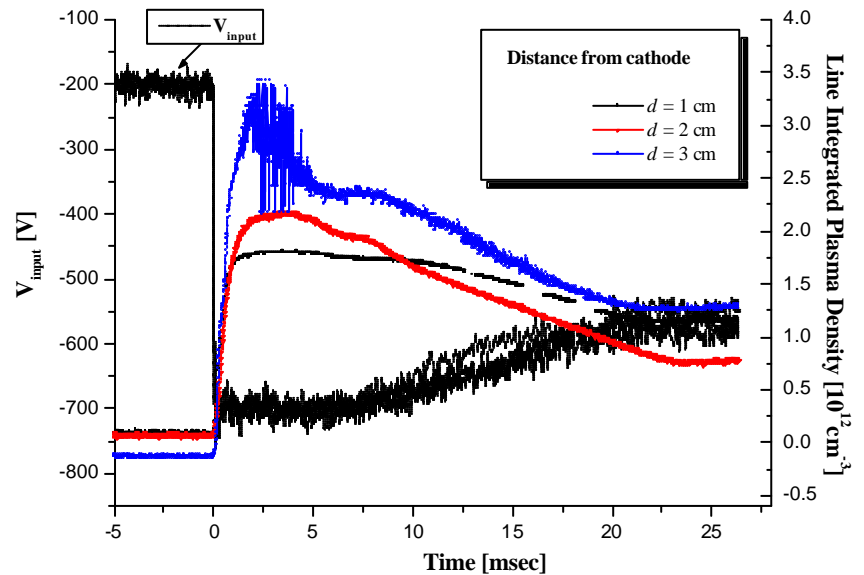
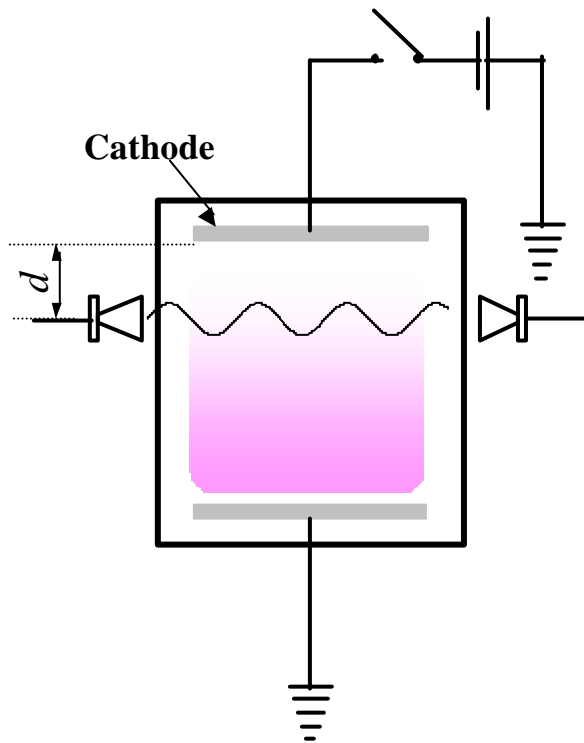
Variation of Plasma density over the DC input

Case III : Variation of rising-time

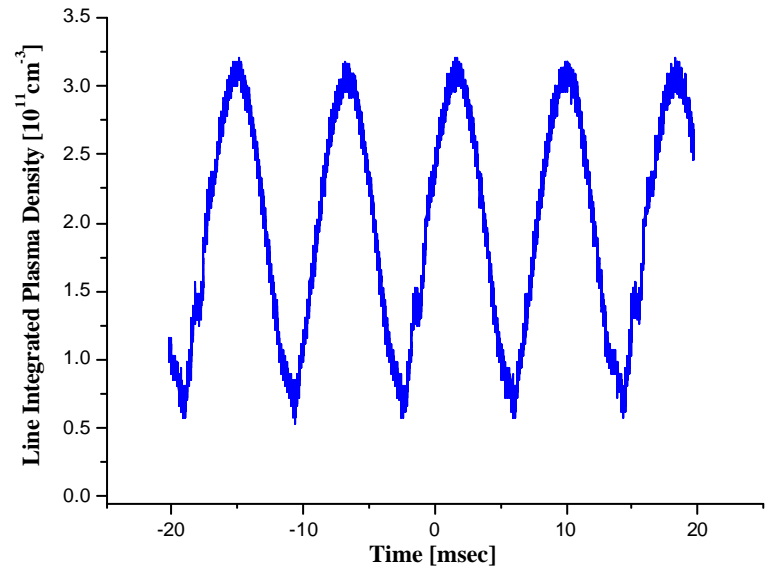
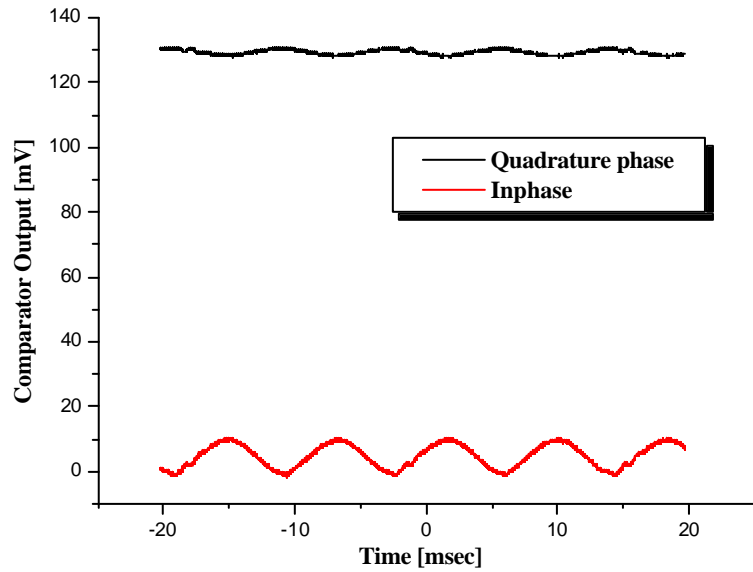


Variation of Plasma density over the DC input

Case IV : Variation of distance from the cathode



Measurement of Plasma Density of Fluorescent Lamp



Conclusions

We have studied the fundamental properties of the plasma generated from DC operation.

- At the beginning of the pulse, plasma density increase steadily, and after that, the density decreases as the charged particles are lost to the surrounding electrodes and recombine into neutrals.
- The time that plasma density reaches a maximum point is determined by pressure.
- The stable state of the plasma is determined by the pulse voltage and pressure (and will be determined by other parameters such as pulse width and duty cycle).
- The line-integrated plasma density of the fluorescent lamp was about $3 \times 10^{11}/\text{cm}^{-3}$.